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P1900.5 Status

- In progress: Draft Ballot comment resolution.
 - 78 people in ballot group
 - 69 voted for 88% response rate, 7& abstention
 - 90% affirmative approval rate
 - 200 comments
 - 82 comments must be satisfied

P1900.5 Status

- In progress: 1900.5.1 PAR comment resolution
 - DySPAN PAR ballot completed/approved.
 - Resolve comments and submit for CSSB approval.